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(71) Applicant (for all designated States except US): **SHA-SUN CHEMICALS AND DRUGS LIMITED [IN/IN]**;  
60 Velacherry Road, Chennai, Tamil Nadu 600042 (IN).

(72) Inventors; and

(75) Inventors/Applicants (for US only):  
**THAKASHINAMOORTHY, Chandiran [IN/IN]**;  
No. 6 Pandian Street, Shankaran Avenue, Velacherry  
Bye-Pass Road, Velacherry, Chennai, Tamil Nadu  
600042 (IN). **SENTHIL, Kumar, Minor [IN/IN]**;  
No. 26, W-Block, Foreshore Estate, Chennai, Tamil Nadu  
600028 (IN). **PALANIVEL, Kaliyaperumal [IN/IN]**;  
No. 98, Mariamman Koil Street, Periyakaraikadu, Sipcot  
Post, Cuddalore TK, Chennai, Tamil Nadu 607 005 (IN).  
**MULLAIYUR, Radhakrishnan, Selvaraju [IN/IN]**;  
Cement Nagar - Post, Sendurai - Taluk., Perambalur -  
Dist, Chennai, Tamil Nadu 621 730 (IN).

(74) Agents: **ANAND, Pravin et al.**; Anand And Anand Advoca-  
tates, B-41 Nizamuddin East, New Delhi 110013 (IN).

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ning of each regular issue of the PCT Gazette.

(54) Title: **AN IMPROVED PROCESS FOR THE MANUFACTURE OF ISRADIPINE.**

(57) Abstract: The present invention relates to an improved method for the manufacture of Isradipine, 4-(4-Benzofurazanyl)-1,4-dihydro-2,6-dimethyl-3,5-pyridinedicarboxylic acid methyl 1-methylethyl ester. which, involves reacting 2,1,3-benzoxadiazole-4-carboxaldehyde with methyl acetoacetate in the presence of acetic acid and piperidine in diisopropyl ether. To obtain the product 2-acetyl-3-benzofurazan-4-yl-acrylic acid methyl ester which is then reacted with isopropyl-8-aminocrotonate in ethanol at 25 to 35°C to obtain the product.

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